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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

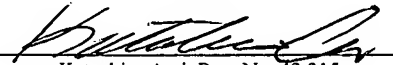
Applicant : HYODO, et al.
App. No : 10/644,195
Filed : August 20, 2003
For : METHOD OF FORMING SILICON-
CONTAINING INSULATION FILM
HAVING LOW DIELECTRIC
CONSTANT AND LOW FILM
STRESS
Examiner : Huynh, Yennhu B
Art Unit : 2813

CERTIFICATE OF MAILING

I hereby certify that this correspondence and all marked attachments are being deposited with the United States Postal Service as first-class mail in an envelope addressed to: Commissioner for Patents, P.O. Box 1450, Alexandria, VA 22313-1450, on

September 30, 2005

(Date)


Katsuhiro Arai, Reg. No. 43,315

STATUS LETTER

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Dear Sir:

Upon review of our records and any available PAIR record, it appears there has been no action in the above-referenced application since Response to Restriction Requirement was filed on February 7, 2005.

Please inform us as to the status of this application.

Respectfully submitted,

KNOBBE, MARTENS, OLSON & BEAR, LLP

Dated: September 30, 2005

By: 

Katsuhiro Arai
Registration No. 43,315
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